

Substitute for form 1449/PTO			Complete if Known		
INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Use as many sheets as necessary)			Application Number	10/568,288-Conf. #3490	
			Filing Date	February 6, 2007	
			First Named Inventor	Juergen Hausselt	
			Art Unit	1724	
			Examiner Name	J. Berman	
Sheet	1	of	1	Attorney Docket Number	31775-226082

U.S. PATENT DOCUMENTS					
Examiner Initials*	Cite No. ¹	Document Number	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Number-Kind Code ² (if known)			

FOREIGN PATENT DOCUMENTS						
Examiner Initials*	Cite No. ¹	Foreign Patent Document	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages Or Relevant Figures Appear	†
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NON PATENT LITERATURE DOCUMENTS			
Examiner Initials	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	†
	CA	Heavens, S.N., Electrophoretic Deposition as a Processing Route for Ceramics in Binner, J. (Ed.), Advanced Ceramic Processing and Technology, Vol. 1, Noyes Publ., Park Ridge, N.J. U.S., 1990	
	CB	Both, H. von; Hausselt, J.: 1 st Intern. Conf. on Electrophoretic Deposition, Banff, Canada, 2002	
	CC	Nitzsche, R. & Simon, F.: TECHNISCHES MESSEN [Technical Measuring] Volume 64, pages 106-113, 1997	

Examiner Signature	/Jason Berman/	Date Considered	12/13/2010
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*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant. * CITE NO. Those application(s) which are marked with a single asterisk (*) next to the Cite No. are not supplied (under 37 CFR 1.98(a)(2)(iii)) because that application was filed after June 30, 2003 or is available in the IPW. † Applicant's unique citation designation number (optional). ‡ See Kind Codes of USPTO Patent Documents at www.uspto.gov or MPEP 901.04. † Enter Office that issued the document, by the two-letter code (WIPO Standard ST.3). ‡ For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. † Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST.16 if possible. ‡ Applicant is to place a check mark here if English language Translation is attached.